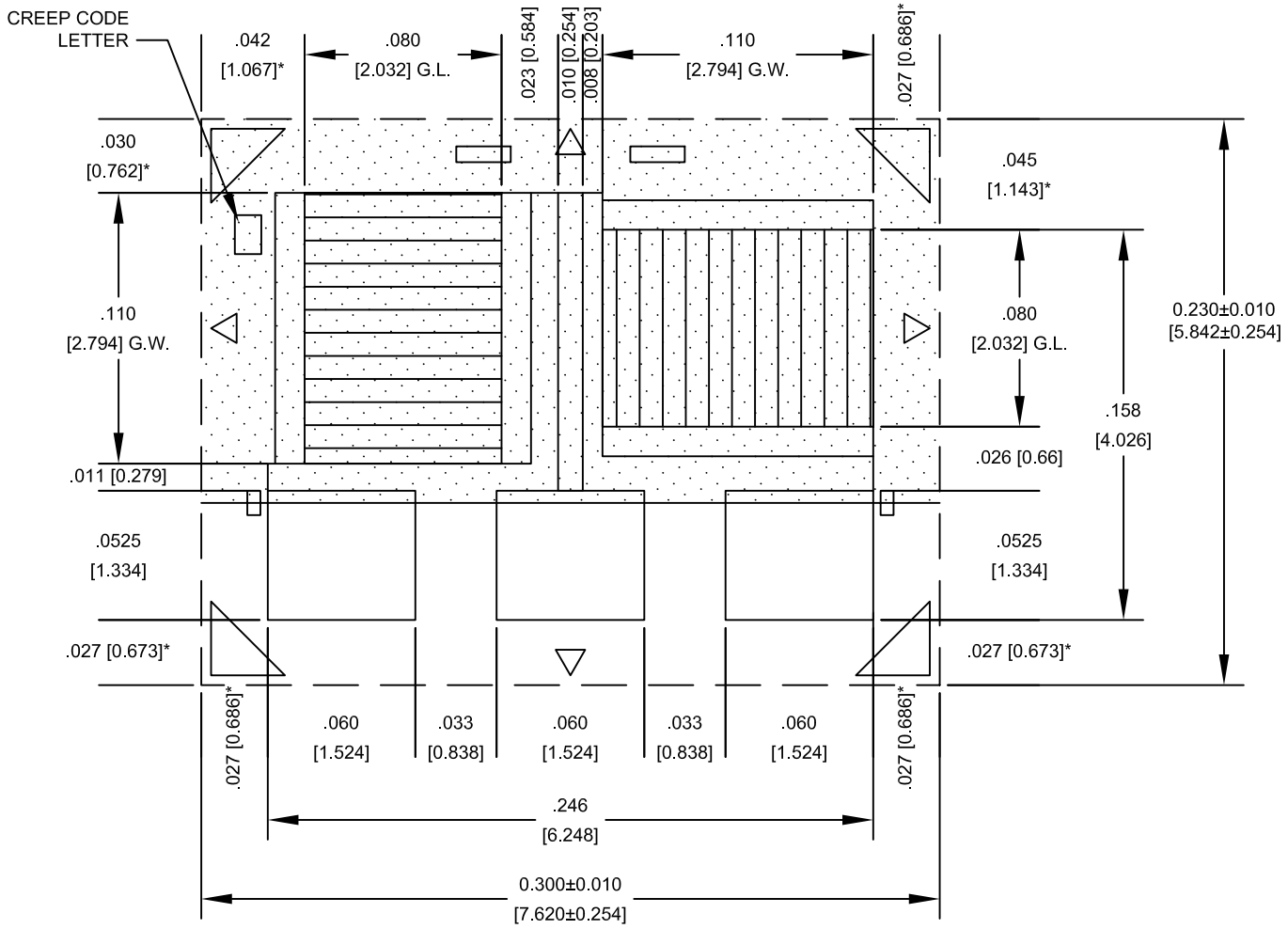
LTR	REVISION	ERN	INITIAL	DATE
~			AR	2014-07-23



* THESE MATRIX RELATED DIMENSIONS ARE ±.0025 [±0.06]

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VISHAY PRECISION GROUP

Micro-Measurements
Raleigh, North Carolina USA

EMEMS®

S5129 PATTERN LAYOUT

CONSTRUCTION:	OPTIONS:
N2A	E3
RESISTANCE:	REFERENCE:
350±0.2%	

DRAWN BY:	DATE:	SCALE:	ALL DIMENSIONS ARE IN INCHES UNLESS OTHERWISE SPECIFIED.
AR	2014-07-23	N.T.S.	
PROJ. ENG.	DATE:	DWG. #	REVISION:
AH	2014-07-23	MS-S5129-10176	~